

Modeling the Performance Impact of Anisotropic Unit Cells Used in Additively Manufactured Luneburg Lenses

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Abstract – Additively manufactured graded index lenses, such as the Luneburg lens, often result in some degree of uniaxial anisotropy in the effective permittivity distribution. A uniaxially anisotropic Luneburg lens modifies the polarization state of an incident electromagnetic field, thus giving rise to a polarization mismatch at the receiving antenna. Using 3D finite element simulation, the lens focal point polarization is analyzed and a model that fits the simulation data is created. The model allows prediction of polarization mismatch loss given any incident field and any receiving antenna polarization without resorting to further time-consuming simulations.

Index Terms – Anisotropic lens, finite element analysis, Luneburg lens, 3D printing.

I. INTRODUCTION

Numerous researchers have reported on the use of sub-wavelength unit cells as fundamental building blocks to additively manufacture graded index components such as the Luneburg lens [1–9]. In these accounts, a 3D printer dispenses precise amounts of material within each unit cell volume, thus controlling the effective permittivity of the cell. Depending upon the complexity of the design, certain fabrication techniques and cell geometries are best suited in terms of manufacturability. Figure 1 provides sketches of two successful unit cell geometries that have been implemented. In (a), the researchers employ a lattice of ultraviolet-curable polymer cubes with interconnecting rods [3], and, indeed, this design is isotropic. The implementation uses a polymer-jetting technique that requires an interposed water-soluble polymer that supports the lattice as it is being printed. This material must then be thoroughly flushed out of the part before use. For complex or large designs with small unit cells, this flushing process of removing support material

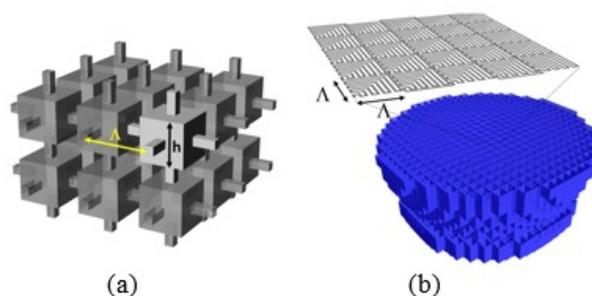


Fig. 1. Unit cell geometries that have been created for 3D printing of graded index components. (a) UV-curable polymer cubes with interconnecting rods and (b) planar unit cell. A indicates the size of the unit cell, which is much smaller than the free-space wavelength at the intended operating frequency

may be problematic. Furthermore, the UV curable polymers used in polymer-jetting have significantly higher loss tangents than thermoplastics [10]. For large designs, this results in an appreciable reduction in radiation efficiency. In (b), the authors in [1, 2] overcome these difficulties by using a planar unit cell, which is printed from a filament of melted thermoplastic, in a process known as fused deposition modeling. This technique produces a cost-effective, low loss, and sturdy design, without the need for a support material. However, the planar unit cell is uniaxially anisotropic. This anisotropy has been recognized by the authors in [1, 2], but its impact on lens performance has yet to be investigated.

Thus, this work uses 3D finite element simulations and post-processing to examine the performance impact of this unit cell anisotropy. A model is created to fit the field at the focal point, which then enables prediction of polarization state without further finite element simulation. The outline for the subsequent portion of the paper

is as follows. Section II discusses the simulation environment, including an analysis of error. Section III provides the details of the anisotropy model that is incorporated into the simulations. Section IV develops the simplifying focal point model and Section V applies this model to predict polarization loss. Section VI then discusses the primary results.

II. SIMULATION ENVIRONMENT

The MATLAB partial differential equation (PDE) toolbox [11] is used to perform 3D finite element analysis of an anisotropic Luneburg lens illuminated by a monochromatic uniform plane wave. The toolbox is used to mesh the computational domain composed of the lens and free space and solve for the scattered field. Upon completion, the scattered field is summed with the incident field to obtain the total field solution [12].

The computational domain is meshed using tetrahedral elements that have a maximum edge length of $l_{\max} \leq 0.1\lambda$, where λ is the free-space wavelength of the incident field. The computational domain is bounded by a sphere of radius $r_b = r_l + 0.5\lambda$ that is concentric around the lens of radius r_l . A first-order absorbing boundary condition [12] is used over the bounding spheres surface. Due to the rotational symmetry of the lens about the z -axis, the direction vector \vec{k} of the incident field is confined to the x, z plane. The sketch in Figure 2 identifies the geometry of the simulation scenario excluding the outer spherical boundary, and a summary of simulation parameters is provided in Table 1.

Referring to the solver category in Table 1, `lsqr()` and `equilibrate()` are both core MATLAB functions designed

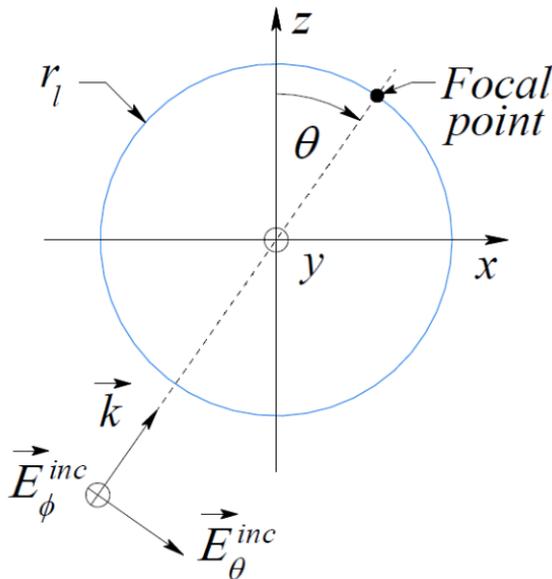


Fig. 2. Incident plane wave, lens, and focal point.

Table 1: Simulation parameters

Category	Parameter	Value
Model	Frequency	15 GHz
	Plane wave polarization	Left hand circular
	Domain radius	$r_l + 0.5\lambda$
	Boundary conditions	First-order absorbing
Mesh	Max. edge length	0.1λ
	Nodes per element	4
	Growth rate	1.5
Solver	Type	<code>lsqr()</code>
	Tolerance	0.1×10^{-3}
	Matrix conditioning	<code>equilibrate()</code>

Table 2: Evaluation of simulation error with isotropic reference lens

r_l	$\angle E_\phi - \angle E_\theta - 90^\circ$	$ E_\phi / E_\theta - 1$
2.5λ	$+3.37^\circ$	+0.011
3.5λ	-2.25°	-0.017
5.0λ	-1.21°	+0.001
RMS error	2.44°	0.012

to operate on sparse matrices. `lsqr()` implements the least squares method to solve the linear matrix equation $Ax = b$ for x . `equilibrate(A)` is used to transform the linear system into an equivalent system that is very stable, prior to solution with `lsqr()`. Although the PDE toolbox provides `solvepde()` for this purpose, the underlying `solveStationary()` routine is not suitable for large problems, and in such cases, it is necessary to substitute an iterative solver such as `gmres()` or `lsqr()`. For the problems in this study, it was found that `lsqr()` performed the best. Another PDE toolbox function that is very useful is `createPDEResults()`. This utility function packs the solution x into a structure that is identical to that returned by `solvepde()`. Drop-in compatibility is achieved by invoking this function before returning from a custom solver routine which may itself call either `gmres()` or `lsqr()`.

Parameters l_{\max} and r_b have been chosen after experimentation, with the intent of striking a balance between solution fidelity and simulation efficiency. This experimentation includes evaluating isotropic reference lens simulations, which are shown in Table 2.

In this evaluation, three isotropic lenses of varying radii are illuminated with a left hand circularly polarized (LCP) plane wave. Given the incident field is LCP, the phase difference $\angle E_\phi - \angle E_\theta$ at the focal point should precisely be equal to 90° , and the polarization ratio $|E_\phi|/|E_\theta|$ should precisely be equal to 1.0. However, since $r_b < \infty$ and $l_{\max} > 0$, the observed root mean square (RMS) error is 2.44° in phase and 0.012 in polarization ratio.

Table 3: Evaluation of simulation error with polar illumination of anisotropic lens

r_l	$\angle E_\phi - \angle E_\theta - 90^\circ$	$ E_\phi / E_\theta - 1$
2.5λ	-0.43°	+0.013
3.5λ	$+0.94^\circ$	-0.018
5.0λ	$+1.60^\circ$	-0.026
RMS error	1.10°	0.020

A similar evaluation involves illuminating three uniaxially anisotropic lenses of varying radii, with an LCP plane wave at a polar angle of $\theta = 0^\circ$. The results of this test are shown in Table 3. Since the illumination is parallel to the optic axis of the lens, both E_ϕ and E_θ experience equivalent material properties. Ideally then, the polarization state at the focal point should equal that of the incident wave, i.e., a $+90^\circ$ phase difference with a polarization ratio of 1.0 (just as in the isotropic case). The observed RMS error in this case is 1.10° in phase and 0.02 in polarization ratio. The observed errors in both the isotropic and anisotropic tests are deemed acceptable.

III. MODELING OF LENS ANISOTROPY

The model used herein follows the findings of researchers in [1, 2] who showed that because of the additive manufacturing process and choice of cell geometry, the lens exhibits a negative uniaxial anisotropy in which

$$\epsilon_x = \epsilon_y = \epsilon_{xy} \geq \epsilon_z. \quad (1)$$

Moreover, the permittivities along the x - and y -axes of the lens follow the Luneburg profile exactly. That is, for any point within the lens at a radial distance r from the lens center

$$\epsilon_{xy} = 2 - \left(\frac{r}{r_l}\right)^2. \quad (2)$$

The permittivity of the lens along the z -axis is modeled by the fractional mixing formula

$$\epsilon_z = \epsilon_{xy}(1 - \alpha) + \alpha \epsilon_{MG}, \quad (3)$$

where α is a parameter (the purpose of which is explained shortly) and ϵ_{MG} represents the effective relative permittivity determined by the Maxwell Garnett (MG) mixing rule for spherical inclusions embedded in a host medium [13]. For a host medium of free space, it is given by

$$\epsilon_{MG} = 1 + 3f \frac{(\epsilon_i - 1)}{\epsilon_i + 2 - f(\epsilon_i - 1)}. \quad (4)$$

Here, ϵ_i represents the relative permittivity of the inclusions, and f represents the volume fill fraction of a unit cell, i.e., the volumetric ratio of material to free space within the cell. In the context of this work, ϵ_i is the relative permittivity of the dielectric material used to print the lens, which is taken as pure thermoplastic

Table 4: Comparison of mixing rules to RCWA

Mixing rule	RMS difference
Maxwell Garnett	0.064
Bruggeman	0.098
Coherent-potential	0.109

with a ϵ_i of 2.60. The authors in [1, 2] determined ϵ_z for the exact unit cell geometry of Figure 1(b) using rigorous coupled wave analysis (RCWA). It is a testament to the scope of Equation (4) in that it generates results that closely match their analysis. It is also fortunate since the alternative is to model the structural geometry of the lens down to the unit cell. To do so accurately would require a mesh fine enough to accurately capture its smallest feature, that being the cell thickness of 0.12 mm [1]. Ultimately, this requires a mesh l_{\max} 160 times smaller and a memory requirement on the order of 160^3 times greater than that used for the present study. This is not feasible since for a lens with $r_l = 2.5\lambda$, this amounts to a memory requirement of 2.2×160^3 gigabytes or equivalently 8.6 petabytes.

Table 4 compares the MG mixing rule to the Bruggeman and coherent-potential mixing rules [13] in terms of fitting the RCWA predictions of ϵ_z as reported in [1, 2]. The table provides the RMS difference between the respective mixing rule and those results. The MG mixing rule has the least RMS difference, thus providing the best fit.

A linear relationship between f and ϵ_{xy} is assumed, such that

$$f = \frac{(\epsilon_{xy} - 1)}{(\epsilon_i - 1)}. \quad (5)$$

Finally, in Equation (3), the parameter α can range from 0 to 1 and is used to simulate designs that exhibit lesser degrees of anisotropy. For example, setting α equal 0 generates a fully isotropic lens design since $\epsilon_z = \epsilon_{xy}$, whereas setting α equal 1 generates the highest degree of anisotropy producing $\epsilon_z = \epsilon_{MG}$. The MG equation with $\epsilon_i = 2.60$ is plotted in Figure 3 for four values of α . The plot highlights the fact that for a chosen ϵ_i , the maximum fill fraction is 0.625 which occurs at the lens center where $\epsilon_z = 2.0$.

IV. MODELING OF POLARIZATION

A. Illumination normal to optic axis

In this subsection, the lens is examined when it is illuminated with a plane wave normal to the z -axis of the lens. Referring to Figure 2, θ is therefore 90° and the incident field is simply directed along the x -axis of the lens. The incident field is represented as

$$\vec{E}^{\text{inc}} = \begin{bmatrix} E_\theta^{\text{inc}} \\ E_\phi^{\text{inc}} \end{bmatrix} = \begin{bmatrix} a_\theta^{\text{inc}} e^{j\psi_\theta^{\text{inc}}} \\ a_\phi^{\text{inc}} e^{j\psi_\phi^{\text{inc}}} \end{bmatrix} e^{-jk_0x}, \quad (6)$$

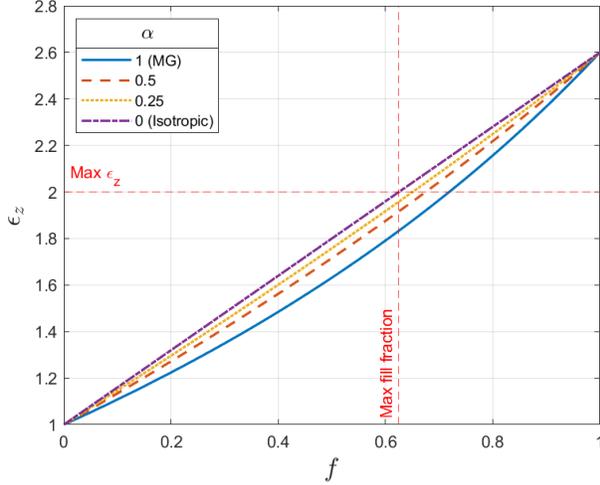


Fig. 3. ϵ_z vs. f for different α . Maximum ϵ_z occurs at lens center where $f = 0.625$.

where a_θ^{inc} and a_ϕ^{inc} are real positive constants, ψ_θ^{inc} and ψ_ϕ^{inc} are real phase constants, and $k_0 = 2\pi/\lambda$. The illumination is LCP, where $a_\theta^{\text{inc}} = a_\phi^{\text{inc}}$, and the phase difference $\psi_\phi^{\text{inc}} - \psi_\theta^{\text{inc}} = 90^\circ$. For a lens of radius r_l , the focal point is located on the surface of the lens, at the cartesian coordinate $(r_l, 0, 0)$. To assess the polarization at the focal point, the radial component of the resultant field at the focal point is ignored, leaving

$$\vec{E} = \begin{bmatrix} a_\theta e^{j\varphi_\theta} \\ a_\phi e^{j\varphi_\phi} \end{bmatrix}, \quad (7)$$

where a_θ and a_ϕ are real positive values, and φ_θ and φ_ϕ are real phase terms and are different from the incident field constants in Equation (6). To describe the polarization state of the focal point, only the ratio $\sigma = a_\phi/a_\theta$ and the phase difference $\delta = \varphi_\phi - \varphi_\theta$ are required [15]. To create a simplifying polarization model of the lens that is independent of the incident field polarization state, the phase imbalance attributed to the lens itself is distinguished from δ . We refer to this as the retardance of the lens $\hat{\delta}$, which is defined here as

$$\hat{\delta} = \delta - (\psi_\phi^{\text{inc}} - \psi_\theta^{\text{inc}}). \quad (8)$$

A similar distinction is required for the polarization ratio σ . Thus, we define the lens polarization ratio $\hat{\sigma}$ as being the polarization ratio measured at the focal point to σ^{inc} , the polarization ratio of the incident field:

$$\hat{\sigma} = \frac{\sigma}{\sigma^{\text{inc}}} = \frac{a_\phi/a_\theta}{a_\phi^{\text{inc}}/a_\theta^{\text{inc}}}. \quad (9)$$

Both $\hat{\sigma}$ and $|\hat{\delta}|$ take on maximum values when the illumination is normal to the optic axis. Under this condition, $\hat{\sigma}$ is referred to as $\hat{\sigma}_m$, and $\hat{\delta}$ is referred to as $\hat{\delta}_m$. Note that when the illumination is parallel, the optic axis $\hat{\sigma} = 1$ and $\hat{\delta} = 0$.

Table 5: Polynomial coefficients for $\hat{\delta}_m$

α	p_1	p_2
1.0	-0.5209	0.0828
0.5	-0.2433	0.0264
0.25	-0.1195	0.01118

In the following two figures, the simulation results for $\hat{\delta}_m$ and $\hat{\sigma}_m$ are plotted using an r_l from 0.5λ to 6λ , in 0.5λ increments. These results are shown for three values of the MG fractional anisotropy constant α . This data is plotted with solid lines and markers. Additionally, polynomial least square fits to $\hat{\delta}_m$ and $\hat{\sigma}_m$ are plotted using dashed curves without markers; this data is comparatively smooth and sampled at a much finer resolution.

The least square fit for $\hat{\delta}_m$ is given by the first-order polynomial below and plotted with simulation data in Figure 4:

$$\hat{\delta}_m = p_1[\alpha]\bar{r}_l + p_2[\alpha], \quad (10)$$

where $\hat{\delta}_m$ is specified in radians, $\bar{r}_l = r_l/\lambda$ and is unitless, and p_1 and p_2 are real coefficients given in Table 5. Note that in Equation (10), the square brackets indicate that α is being treated as a lookup table index – not a continuous variable.

$\hat{\sigma}_m$ is treated as a function of $\hat{\delta}_m$, and, as can be inferred from Figure 4, $\hat{\delta}_m < 0^\circ$. Moreover, a piecewise model of $\hat{\sigma}_m$ is necessary, expressed herein as

$$\hat{\sigma}_m = \begin{cases} \hat{\sigma}_m^a, & \text{if } -180^\circ \leq \hat{\delta}_m \\ \hat{\sigma}_m^b, & \text{otherwise.} \end{cases} \quad (11)$$

As $\hat{\delta}_m$ is varied from 0° to -180° , it is observed that a_ϕ increases linearly, whereas a_θ increases non-linearly and settles into a plateau as $\hat{\delta}_m$ approaches -180° . For $-180^\circ \leq \hat{\delta}_m$, the least square fit for $\hat{\sigma}_m$ is given by the

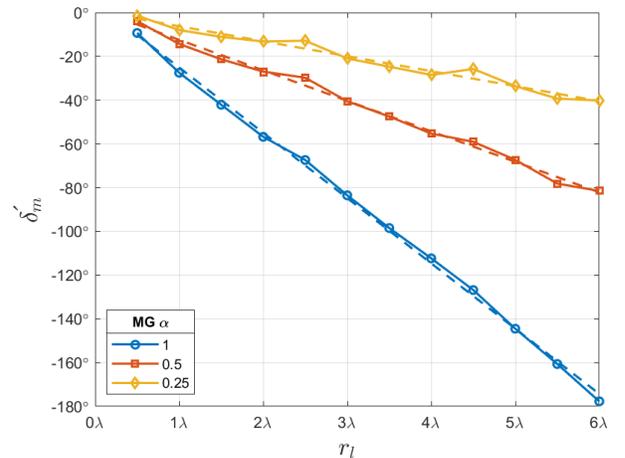


Fig. 4. $\hat{\delta}_m$ vs. r_l for different α . Dashed lines are model given by least square fit in Equation (10).

Table 6: Polynomial coefficients for $\hat{\sigma}_m^a$

q_1	q_2	q_3
0.07122	-0.1148	0.9999

second-order polynomial below, and plotted with simulation data in Figure 5:

$$\hat{\sigma}_m^a = q_1 \hat{\delta}_m^2 + q_2 \hat{\delta}_m + q_3, \quad (12)$$

where q_1 , q_2 , and q_3 are the real coefficients given in Table 6.

As $\hat{\delta}_m$ decreases beyond -180° , a_ϕ continues to increase linearly, whereas a_θ is fixed at the plateau value. Therefore, $\hat{\sigma}_m$ is linear in this region and is given by

$$\hat{\sigma}_m^b = q_4 \hat{\delta}_m + q_5, \quad (13)$$

where the coefficients q_4 and q_5 are determined as follows. To ensure a differentiable, and thus continuous, piecewise model, the slope of the line defined by Equation (13) must equal the derivative of Equation (12) at $\hat{\delta}_m = -\pi$. Therefore

$$q_4 = \left. \frac{d\hat{\sigma}_m^a}{d\hat{\delta}_m} \right|_{\hat{\delta}_m = -\pi} = -2q_1\pi + q_2. \quad (14)$$

Now, upon substituting Equation (14) into Equation (13), setting $\hat{\sigma}_m^b = \hat{\sigma}_m^a$ and solving for q_5 at $\hat{\delta}_m = -\pi$ yields

$$q_5 = \left(\hat{\sigma}_m^a - q_4 \hat{\delta}_m \right) \Big|_{\hat{\delta}_m = -\pi} = q_3 - q_1 \pi^2. \quad (15)$$

The piecewise model for $\hat{\sigma}_m$ therefore transitions smoothly between a second-order and a first-order polynomial at $\hat{\delta}_m = 180^\circ$.

Equation (10) and (11), therefore, predict the extent to which the incident polarization state is altered when

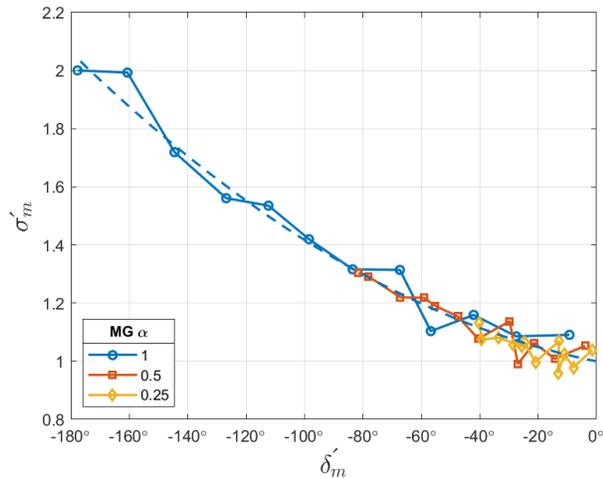


Fig. 5. $\hat{\sigma}_m$ vs. $\hat{\delta}_m$ for different α . Dashed curve is the model given by least square fit in Equation (12). For $\hat{\delta}_m < -180^\circ$, the model transitions smoothly into the linear relationship given by Equation (13).

the incident wave is normal to the optic axis of the lens.

B. Illumination at arbitrary polar angle

In this subsection, the impact of the lens anisotropy is examined as the polar angle θ of the incident field is swept from 0° to 90° in 11.25° increments. The incident field is therefore defined as

$$\vec{E}^{\text{inc}} = \begin{bmatrix} a_\theta^{\text{inc}} e^{j\psi_\theta^{\text{inc}}} \\ a_\phi^{\text{inc}} e^{j\psi_\phi^{\text{inc}}} \end{bmatrix} e^{-jk_0(x\sin(\theta) + z\cos(\theta))}. \quad (16)$$

In this experiment, three different lens radii are studied: 2.5λ , 3.5λ , and 5λ . It is observed that $\hat{\delta} = 0$ when the incident field is parallel to the optic axis, i.e., $\theta = 0^\circ$, and $\hat{\delta} = \hat{\delta}_m$ when the incident field is normal to it, i.e., $\theta = 90^\circ$. Moreover, the retardance is approximated by

$$\hat{\delta} = \hat{\delta}_m \sin^2(\theta). \quad (17)$$

The retardance computed directly from the 3D finite element simulations and the approximation given in Equation (17) are plotted in Figure 6.

Correspondingly, $\hat{\sigma} = 1$ when the incident field is parallel to the optic axis and $\hat{\sigma} = \hat{\sigma}_m$ when the incident field is normal to it. After experimenting with several approximating functions, the following provides the best fit of $\hat{\sigma}$ to the simulation data:

$$\hat{\sigma} = 1 + \frac{(\hat{\sigma}_m - 1) \left(1 - e^{-(\theta/\tau)^2} \right)}{1 - e^{-(\pi/2\tau)^2}}. \quad (18)$$

In the above equation, θ is specified in radians and τ is a parameter that has been set to 0.6 radians through experimentation. In Figure 7, both the results computed from the 3D finite element simulations and the approximation of Equation (18) are plotted.

Equation (17) and (18), therefore, predict the extent to which the incident polarization state is altered when

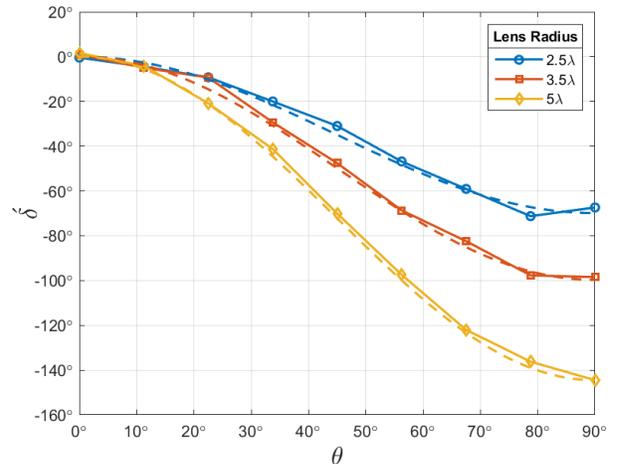


Fig. 6. $\hat{\delta}$ vs. θ for different r_l . Dashed curves are model given by Equation (17).

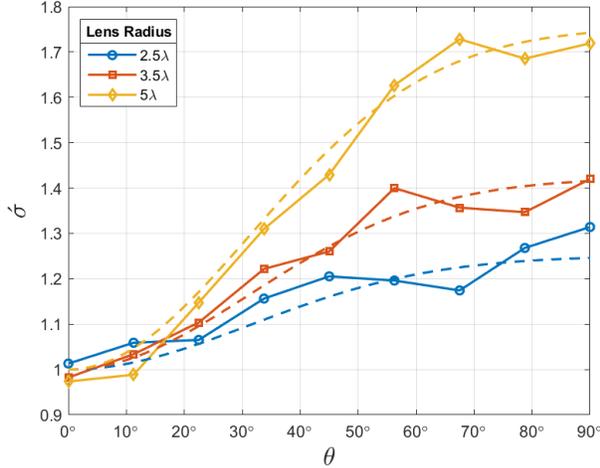


Fig. 7. σ vs. θ for different r_l . Dashed curves are model given by Equation (18).

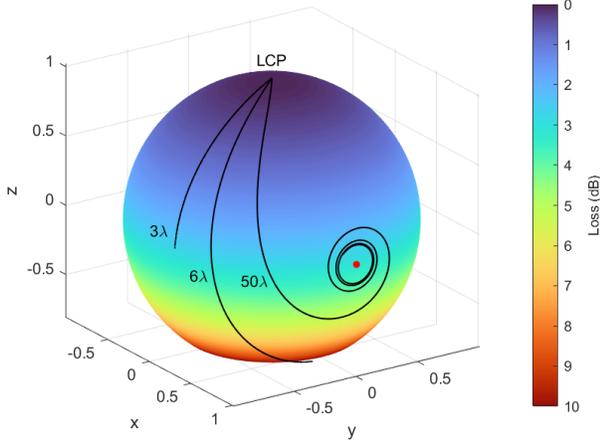


Fig. 8. Paths on Poincaré sphere for different r_l , as θ is swept from 0° to 90° . Surface of sphere indicates the PLF. Red dot is LHP marker. Illumination is LCP.

the incident wave arrives at an arbitrary angle relative to the optic axis of the lens.

V. POLARIZATION LOSS

Other than for the degenerate cases in which either $a_\theta^{\text{inc}} = 0$ or $a_\phi^{\text{inc}} = 0$, the anisotropy of the lens creates a mismatch between the incident and focal point polarizations. Normally, the receiving antenna has a polarization matched to that of the incident field. When the lens alters the incident polarization, the ability of the antenna to transfer focal power to the load is reduced. A non-dissipative loss is associated with this inefficiency and is termed the polarization loss factor (PLF). It is defined as follows [14]:

$$\text{PLF} = 10 \log_{10}(\Gamma), \quad (19)$$

Finally, in Figure 9, the model provides PLF for a relatively wide range of lens radii with LCP illumination.

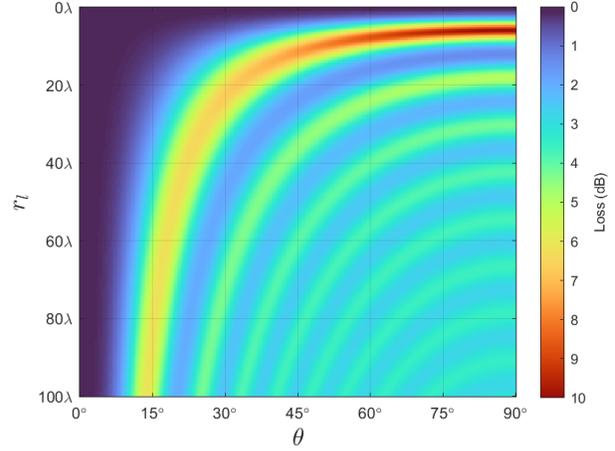


Fig. 9. PLFs as r_l and θ are varied. Compare with results on Poincaré sphere. Illumination is LCP.

The loss over most of the image is ≈ 3 dB, indicating a focal point that is nearly horizontally polarized. where

$$\Gamma = |\hat{\rho} \cdot \hat{\rho}_r^*|^2 = |\cos(\psi_r)|^2. \quad (20)$$

In Equation (20), $\hat{\rho}$ is the unit polarization vector of the field at the focal point, $\hat{\rho}_r^*$ is the complex conjugate of the unit polarization vector for the receiving antenna, and ψ_r is the angle between the two. Since Equation (7) can be expressed as

$$\vec{E} = a_\theta e^{j\varphi_\theta} \begin{bmatrix} 1 \\ \sigma e^{j\delta} \end{bmatrix}, \quad (21)$$

then the direction of \vec{E} , and therefore $\hat{\rho}$, must depend only on σ and δ . Thus

$$\hat{\rho} = \frac{1}{\sqrt{1 + \sigma^2}} \begin{bmatrix} 1 \\ \sigma e^{j\delta} \end{bmatrix}. \quad (22)$$

To compute the PLF using the focal point polarization model developed in the previous section, we first use Equation (17) to compute δ and Equation (18) to compute σ . Both values are independent of the incident field's polarization; therefore, we use Equation (8) to solve for δ and Equation (9) to solve for σ . In other words

$$\delta = \delta + (\psi_\phi^{\text{inc}} - \psi_\theta^{\text{inc}}), \quad (23)$$

and

$$\sigma = \sigma \sigma^{\text{inc}}. \quad (24)$$

An insight into the dependence of the PLF on r_l and θ is obtained by tracing the focal point polarization state on a Poincaré sphere that is PLF colorized according to the incident field. This is accomplished efficiently using the model developed in the previous section along with Equation (19), (23), and (24). Figure 8 provides such results for lens radii of 3λ , 6λ , and 50λ , all illuminated with LCP. For each lens, as θ is swept from 0° to 90° , the state moves away from the zero loss LCP

state. A maximum loss of ≈ 10 dB is observed when $r_l = 6\lambda$. For $r_l = 50\lambda$, the maximum loss drops to ≈ 6 dB, and the state follows a spiraling path toward the linear horizontally polarized (LHP) state, denoted as a red dot. Larger lenses produce even tighter spirals around the LHP state and incur a maximum loss that asymptotically approaches 3 dB.

VI. CONCLUSION

A uniaxially anisotropic Luneburg lens modifies the polarization state of an incident wave, thus introducing a polarization mismatch loss at the focal point. This mismatch is dependent upon the wave polarization, the degree of anisotropy, the radius of the lens, and the wave angle of arrival. For $r_l \gg \lambda$, the anisotropy strongly polarizes the focal point along the horizontal plane. This mismatch is undesirable in most circumstances, and minimizing it requires prediction of the unit cell permittivities along the x -, y - and z -axes.

We show that curve fitting of 3D finite element simulations provides an efficient method to model the retardance and polarization ratio of the lens. This model and knowledge of the incident wave and receiving antenna polarizations are sufficient to predict the amount of polarization mismatch loss, enabling the selection of isotropic unit cell geometries that are suitable for fused deposition modeling.

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